

In re application of : Confirmation No. 5520

Hiroki MAEDA et al. : Attorney Docket No. 2006 0043A

Serial No. 10/565,104 : Group Art Unit 1753

Filed January 19, 2006 : Examiner Anca Eoff

PHOTOSENSITIVE RESIN COMPOSITION: AND METHOD OF FORMING A PATTERN

USING THE COMPOSITION

Mail Stop: AMENDMENT

PETITION FOR SUSPENSION OF ACTION UNDER 37 CFR 1.103(a)

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450 THE COMMISSIONER IS AUTHORIZED TO CHARGE ANY DEFICIENCY IN THE FEES FOR THIS PAPER TO DEPOSIT ACCOUNT NO 23-0975

Sir:

Applicants hereby request that action in this application be delayed for two months from the date of this Petition i.e. until March 8, 2008 in order to provide adequate time to prepare a Declaration Under 37 CFR 1.131.

Each of the present inventors is currently living in different locations thus making the preparation of the Declaration more time consuming.

Accordingly, granting of this Petition is respectfully requested.

The Petition fee as set forth in 37 CFR 1.17(g) accompanies.

Respectfully submitted,

Hiroki MAEDA et al.

By:

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